	Hits	Search Text	DBs	Time Stamp
1	11920	boron near (implanting implantation implanted implant)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/09 16:14
2	57	("6562418" "6436785" "6417031" "6391694" "6380012" "6300209" "6150248" "6133120" "6090590" "5964943" "6097079" "5913131" "5885904" "5866472" "5763320" "5709745" "5672541" "5598025" "5199994" "5198373" "5037767" "4791005" "4692998" "4682564" "4676847" "4318213" "4371587").pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:28
3	14	S1 and S2	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:28
4	17	boron near (implanting implantation implanted implant) and solid adj boron	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:30
5	3	"6904509".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:28
6	0	S1 and S5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:31
7	290	solid adj boron	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/09 16:13
8	1135	solid adj3 boron	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:31

	Hits	Search Text	DBs	Time Stamp
9	65	S1 and S8	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:31
10	39	solid adj boron and boron adj2 (ion ions plasma)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:32
11	107	S8 and boron adj2 (ion ions plasma)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/09 16:09
12	85	solid adj boron and semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:32
13	319	solid adj3 boron and semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB	2005/07/08 10:32
14	80	solid adj3 boron and semiconductor and boron adj2 (ion ions plasma)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB	2005/07/08 10:34
15	27	solid adj boron and semiconductor and boron adj2 (ion ions plasma)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB	2005/07/08 10:34
16	43	solid adj3 boron and semiconductor and boron adj2 (ion ions plasma) and S1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:34
17	12	solid adj boron and semiconductor and boron adj2 (ion ions plasma) and S1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:34

	Hits	Search Text	DBs	Time Stamp
18	117		US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:45
19	13	438/513.ccls. and S1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:45
20	2	438/513.ccls. and S1 and (S7 S8)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:46
21	5	438/513.ccls. and (S7 S8)	(H:D() • . D() •	2005/07/08 10:46
22	1086	438/514.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:45
23	119	438/514.ccls. and S1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:45
24	4	438/514.ccls. and S1 and (S7 S8)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:46
25	6	438/514.ccls. and (S7 S8)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/08 10:46
26	1135	solid adj3 boron	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/09 16:09

	Hits	Search Text	DBs	Time Stamp
27	10	S26 and boron adj2 (ion ions plasma) and germanium	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/09 16:11
28	5	S26 and boron adj2 (ion ions plasma) and germanium with boron	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/09 16:11
29	17		US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/09 16:13
30	73	implantation implanted implant)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/09 16:14
31	38	implantation implanted implant) with germanium and boron adi	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/07/09 16:15